



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<b>AMENDMENT</b>		ATTORNEY DOCKET NO. <b>70020.0058US01</b>
		U.S. APPLICATION SERIAL NO. <b>10/743,809</b>
		CONFIRMATION NO. <b>1719</b>
		FILING DATE <b>December 24, 2003</b>
INVENTOR(S) <b>Eiji YONEDA et al.</b>	EXAMINER <b>Rosemary Ashton</b>	GROUP ART UNIT <b>1752</b>
TITLE OF APPLICATION <b>ONIUM SALT COMPOUND AND RADIATION SENSITIVE RESIN COMPOSITION</b>		

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed September 8, 2005, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims that begins on page 2 of this paper.

**Remarks** begin on page 20 of this paper.

01/09/2006 SZEWDIE1 00000091 132725 10743809

02 FC:1201 1200.00 DA  
03 FC:1202 50.00 DA